

Correction to Photocleavable Triblock Copolymers Featuring an Activated Ester Middle Block: “One-Step” Synthesis and Application as Locally Reactive Nanoporous Thin Films

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In the first paragraph, “For example, Russell and co-workers reported nanoporous thin films from polystyrene-*block*-poly(ethylene oxide) with a disulfide group as a junction.” should be changed to read the following: “For example, Thayumanavan and co-workers reported nanoporous thin films from polystyrene-*block*-poly(ethylene oxide) with a disulfide group as a junction.”

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On page 2 of the Supporting Information, the sentence beginning with “GISAXS measurements were performed...” now reads as “GISAXS measurements were performed on beamline 7.3.3 at the Advanced Light Source at the Berkeley National Laboratory. The wavelength of X-rays used was 1.24 Å, and the scattered intensity was detected using a 2D charge-coupled device (CCD) camera or a Pilatus 100k fast detector”.

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